

JANUARY, 2007

## **Curriculum Vitae**

### **1. PERSONAL DETAILS**

Name: Lior Miller  
ID No: 031978414  
Date of Birth: December 27, 1974.  
Place of Birth: Haifa, Israel.  
Citizenship: Israeli  
Marital status: Married, one daughter.  
Home address: 18a Ha'emek Street, Kiryat Tivon, 36084, Israel  
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### **2. ACADEMIC DEGREES**

2007-            PhD. student, Purdue  
                  Supervisor: Prof. Alex King

2004-2006    Technion-Israel Institute of Technology, Department of Materials Engineering,  
                  M.Sc. Research topic: "Processing and Microstructure of Aluminum Oxynitride  
                  (ALON)".  
                  Supervisor: Assoc. Prof. Wayne D. Kaplan

1999-2004    Technion-Israel Institute of Technology, Double Major: B.Sc. in Materials  
                  Engineering *and* B.A in Chemistry. Cum Laude

### **3. TEACHING EXPERIENCE:**

Teaching assistant in the Department of Materials Engineering, for the following courses:

1. Microstructural Characterization of Materials.
2. Introduction to Materials Engineering.
3. Advanced laboratory for Materials Engineering – Scanning Electron Microscopy.

#### 4. PROFESSIONAL BACKGROUND

- 2006- Do Coop Technologies, Consultant for Materials Engineering and Electron Microscopy.
- 2001-3/2004 Lab assistant, Ceramic Laboratory, Department of Materials Engineering, Prof. Wayne D. Kaplan, Technion, Haifa, Israel.
- 1999-2001 Security officer in the "Internal General Security Service of Israel"
- 1997-1999 Bodyguard of senior public officials in the "Internal General Security Service of Israel" (Shabak).

#### 5. CONFERENCES

1. Lior Miller and Wayne D. Kaplan, "Solubility Limits of La and Y in Aluminum Oxynitride (AlON) at 1870°C", Presented at the 40<sup>th</sup> Annual Meeting - Israel society for Microscopy (ISM), May 10-11 2006, Kibbutz HaGoshrim, Israel
2. Lior Miller and Wayne D. Kaplan, "Solubility Limits of La and Y in Aluminum Oxynitride (AlON) at 1870°C", oral presentation at the 12<sup>th</sup> Israel Materials Engineering Conference (IMEC-12), March 1-2, 2006, Beer Sheva, Israel
3. Lior Miller and Wayne D. Kaplan, "Processing Aluminum Oxynitride", Presented at the 107<sup>th</sup> annual meeting of the American Ceramic Society, April 10-13 2005, Baltimore, U.S.A.
4. Lior Miller, Amir Avishi and Wayne D. Kaplan, "Direct Measurements of PPM-Level Solubility Limits in Polycrystalline Ceramics:  $MgO$  in  $Al_2O_3$ ", Presented at the 107<sup>th</sup> annual meeting of the American Ceramic Society, April 10-13 2005, Baltimore, U.S.A
5. Lior Miller, Amir Avishai and Wayne D. Kaplan, "A New Approach to Measuring Solubility Limits of ppm Levels in Polycrystalline Ceramics:  $MgO$  in  $Al_2O_3$ ", Presented at the 38<sup>th</sup> Annual Meeting - Israel society for Microscopy (ISM), May 11 2004, Hebrew University of Jerusalem, Jerusalem, Israel.
6. Lior Miller, Mike Lieberthal and Wayne D. Kaplan, "Processing Aluminum Oxynitride", Presented at the 11<sup>th</sup> Israel Materials Engineering Conference (IMEC-11), December 24 - 25, 2003, Technion - Israel Institute of Technology, Technion City, Haifa, Israel.

## 6. PUBLICATIONS:

1. L. Miller, A. Avishai and W.D. Kaplan, *Solubility Limit of MgO in Al<sub>2</sub>O<sub>3</sub> at 1600°C*, Journal of the American Ceramic Society, **89**[1]: 350-353, 2006.
2. Y. Katsir\*, L. Miller\*, Y. Aharonov and E. Ben Jacob, *The effect of rf-irradiation on electrochemical deposition and its stabilization by nanoparticle doping*, accepted to the Journal of the Electrochemical Society.

\* - These authors have equal contribution

3. L. Miller and W. D. Kaplan, *Water-based Method For Processing Aluminum Oxynitride (AlON)*, in preparation.
4. L. Miller and W. D. Kaplan, *Solubility Limits of La and Y in AlON at 1870°C*, in preparation.

## 7. EXPERIMENTAL METHODS:

1. Scanning Electron Microscope (FEI XL30, FEI Quanta 200) combined with Energy Dispersive Spectroscopy (EDS, Oxford Instruments) and Wavelength Dispersive Spectroscopy (WDS, Oxford Instruments).
2. X-Ray diffractometer (Philips PW-3020).
3. Transmission Electron Microscope (JEOL FX 2000, FEI Tecnai T20).
4. High Resolution Transmission Electron Microscope (JEOL 3010UHR).
5. High Resolution Scanning Electron Microscope (LEO Gemini 982)
6. Computerized Optical Microscope + Advanced Image Analysis toolbox (AnalySIS).

## 8. MILITARY SERVICE

1995-1996	Special combat unit: "Sayaret Egoz"
1993-1995	Special combat unit: "Sayeret Matkal"